

IFW 2125

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Chicambri IIZAWA et al	: Examiner: R. A. Jarrett
Shigeyuki UZAWA et al.) : Group Art Unit: 2125
Application No.: 09/864,309)
Filed: May 25, 2001	: Confirmation No.: 2803
For: EXPOSURE APPARATUS, COATING/DEVELOPING	:)
SYSTEM, DEVICE MANUFACTURING SYSTEM,	July 29, 2005
DEVICE MANUFACTURING METHOD,)
SEMICONDUCTOR MANUFACTURING FACTORY,	:
AND EXPOSURE APPARATUS MAINTENANCE)
METHOD	:

Mail Stop Amendment

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Transmitted herewith is an Amendment in the above-identified application.

X No additional fee is required.

The fee has been calculated as shown below:

			CLAIMS AS AME	ENDED		_
	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NO. PREVIOUSLY PAID FOR	PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL CLAIMS	14	MINUS	47	= 0	x \$25 \$50	\$0.00
INDEP. CLAIMS	1	MINUS	9	= 0	x \$100 \$200	\$0.00
Fee for Multiple Dependent claims \$180/\$360						
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT					\$0.00	

	Verified Statement claiming small entity status is enclosed, if not filed previously.				
	A check in the amount of \$ is enclosed including the additional claims fee.				
	Charge \$ to Deposit Account No. 06-1205. A duplicate of this sheet is enclosed.				
X	Any prior general authorization to charge an issue fee under 37 CFR 1.18 to Deposit Account No. 06-1205 is hereby revoked. The Commissioner is hereby authorized to charge any additional fees under 37 CFR 1.16 and 1.17 which may be required during the entire pendency of this application or to credit any overpayment, to Deposit Account No. 06-1205. A duplicate of this paper is enclosed.				
	A check in the amount of \$ to cover the fee for a two month extension is enclosed.				
	A check in the amount of \$ to cover the Information Disclosure Statement fee is enclosed.				
X	Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should be directed to our address given below.				
	Respectfully submitted,				
	Attorney for Applicants Steven E. Warner Registration No. 33,326				

FITZPATRICK, CELLA, HARPER & SCINTO 30 Rockefeller Plaza New York, New York 10112-3800 Facsimile: (212) 218-2200 SEW/eab

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Shigeyuki UZAWA et al.	<i>)</i>	Group Art Unit: 2125
Application No.: 09/864,309	,	Group Art Offit. 2123
	:	Confirmation No.: 2803
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DEVICE MANUFACTURING METHOD,)	•
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AND EXPOSURE APPARATUS MAINTENANCE)	
METHOD	:	

Mail Stop Amendment

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the Official Action dated April 29, 2005, please amend the aboveidentified application as follows: